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Control of Regioselectivity in the Alkylation of 2-Trimethylsilyl-2,5-dihydrothiophene 1,1-Dioxide. A Route for 2,2-Dialkylation

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The readily available 2-trimethylsilyl-2,5-dihydrothiophene 1,1-dioxide can be converted regioselectively into the dialkyl- and dispiro analogues, which are precursors of the corresponding 1,1-disubstituted buta-1,3-dienes and asymmetric dicycloalkylidenylethanes, respectively.

During studies of the synthetic applications of the direct deprotonation-alkylation reaction of 2,5-dihydrothiophene 1,1-dioxides,¹ we and others have found that one-pot or stepwise dialkylation reactions regioselectively give the 2,5-disubstituted analogues,² but regioselective control of 2,2-dialkylation directly from (1) has never been achieved. The thermolysis of the 2,2-disubstituted products to give the corresponding disubstituted buta-1,3-dienes is well established, (reaction 1).³ We hereby describe an attractive and convenient method for the synthesis of these compounds from the 2-trimethylsilyl derivative (2).

Compound (2) was synthesized in 43% yield by treatment of the anion of (1) with Me₃SiCl–NaI in tetrahydrofuran (THF)–hexamethylphosphoramide (HMPA).⁴ The yield can be improved to 70% by using Me₃SiI in THF (Scheme 1). When (2) in THF was treated with BuⁿLi (1 equiv., -105 °C) and then with MeI (1 equiv.), the 2-methyl-2-trimethylsilyl analogue (3a) was produced in 85% yield (Scheme 1). If 2.5 equiv. of MeI were used and HMPA was added as cosolvent in the same sequence, (3a) was formed along with the 2,2dimethyl compound (5a) and the 2-methyl compound (6a) in





Scheme 1. Reagents and conditions: i, BuⁿLi, THF, -105 °C; ii, Me₃SiI; iii, MeI (1 equiv.).



Scheme 2. Reagents and conditions: i, BuⁿLi, THF-HMPA, -105 °C; RI (2.5 equiv.); iii, I⁻; iv, RI; v, H₂O.



Scheme 3. Reagents and conditions: i, BuⁿLi, THF-HMPA, -105 °C; ii, I-[CH₂]_n-I, -105 °C reflux.



Scheme 4. Reagents and conditions: i, LiHMDS, THF-HMPA, -78 °C; ii, I-[CH₂]₅-I; iii, I-[CH₂]₃-I; iv, I-[CH₂]₄-I.

2:1:1 ratio. No starting material or other products were found in any significant quantity (Scheme 2). Compounds (5a) and (6a) must be formed by a second methylation or a protonation, respectively, from anion (4a) generated by iodide attack on the trimethylsilyl group of (3a).

On refluxing the reaction mixture overnight, (5a) was obtained as the major product in 52% yield. With EtI in place of MeI, (5b) was formed in 61% yield. Using an α, ω -diiodoalkane as the alkylating agent, spiro compounds (7a) (47%), (7b) (52%), or (7c) (56%) could also be produced (Scheme 3). However, a similar reaction with 1,2-di-iodoethane proved to be complex and no cyclized product was observed. Further intramolecular dialkylations of (7a,b,c) with other α, ω -di-iodoalkanes were expected to yield asymmetric dispirocyclic products. Since dicyclohexylidene-ethane is known to be produced in quantitative yield by the thermolysis of the symmetrical 7-thiadispiro[5.1.5.2]pentadec-14-ene 7,7-dioxide,2 it was reasonable to expect the asymmetric dispirocyclic compounds to be precursors of asymmetric dicycloalkylidene-ethanes. When (7b) in THF-HMPA was treated with lithium hexamethyldisilazide (LiHMDS) (2 equiv.) and 1,5-di-iodopentane (1 equiv.), the asymmetric dispirocyclic compound (8) was produced in 61% yield (Scheme 4). Interestingly, the reaction of (7b) with 1,3-di-iodopropane resulted in the formation of the elimination product (9) instead of the dispiro-compound (10) (Scheme 2). However, (10) was obtained in 65% yield by the reaction of (7a) with 1,4-di-iodobutane.

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